# **Charge Separation Part 1: Diode**

#### Lecture 5 – 9/22/2011

#### MIT Fundamentals of Photovoltaics 2.626/2.627 – Fall 2011

Prof. Tonio Buonassisi

#### 2.626/2.627 Roadmap



# 2.626/2.627: Fundamentals

*Every* photovoltaic device must obey:

Conversion Efficiency 
$$(\eta) \equiv \frac{\text{Output Energy}}{\text{Input Energy}}$$

# For most solar cells, this breaks down into:



#### Liebig's Law of the Minimum



S. Glunz, Advances in Optoelectronics 97370 (2007)

#### $\eta_{\text{total}} = \eta_{\text{absorption}} \times \eta_{\text{excitation}} \times \eta_{\text{drift/diffusion}} \times \eta_{\text{separation}} \times \eta_{\text{collection}}$

Image by S. W. Glunz. License: CC-BY. Source: "High-Efficiency Crystalline Silicon Solar Cells." Advances in OptoElectronics (2007).

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# **Diode: Essence of Charge Separation**



- What is a diode?
- How is it made?
- Why care about diodes?

#### **Diode: Essence of Charge Separation**



Courtesy of Adrio Communications Ltd. Used with permission.

http://www.radio-electronics.com/info/data/thermionicvalves/vacuum-tube-theory/tube-tutorial-basics.php

# **Learning Objectives: Diode**

- 1. Describe how conductivity of a semiconductor can be modified by the intentional introduction of dopants.
- 2. Draw pictorially, with fixed and mobile charges, how builtin field of pn-junction is formed.
- 3. Current flow in a *pn*-junction: Describe the nature of drift, diffusion, and illumination currents in a diode. Show their direction and magnitude in the dark and under illumination.
- 4. Voltage across a *pn*-junction: Quantify the built-in voltage across a *pn*-junction. Quantify how the voltage across a *pn*-junction changes when an external bias voltage is applied.
- 5. Draw current-voltage (I-V) response, recognizing that minority carrier flux regulates current.

# **Dopant Atoms**





#### **Carrier Binding Energy to Shallow Dopant Atoms**



Carrier binding energy to a shallow (hydrogenic) dopant atom:

$$E = E_{\rm H} \frac{m^*}{m_{\rm e}} \frac{1}{\varepsilon^2} = (13.6 \text{ eV}) \cdot \frac{m^*}{m_{\rm e}} \frac{1}{\varepsilon^2}$$

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#### **Gauss' Law: Review**

#### Spatially variant fixed charge creates an electric field:

$$\frac{d\xi}{dx} = \frac{\rho}{\varepsilon}$$

 $\xi$  = electric field  $\rho$  = charge density  $\varepsilon$  = material permittivity

**Example:** Capacitor

$$\nabla \cdot \xi = \frac{\rho}{\varepsilon}$$



Image by MIT OpenCourseWare.

#### Gauss' Law: Review

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#### Drift Current: Net charge moves parallel to electric field



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#### **Diffusion: Review**



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From PVCDROM

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#### **Recall the Checker Board Example**





# Let's imagine the n- and p-type materials in contact, but with an imaginary barrier in between them.

#### How a pn-junction comes into being



With the P and N type materials separated the carriers diffuse around randomly.

Courtesy of PVCDROM. Used with permission.

# When that imaginary boundary is removed, electrons and holes diffuse into the other side.

# How a pn-junction comes into being



Courtesy of PVCDROM. Used with permission.

Eventually, the accumulation of like charges [(h<sup>+</sup> + P<sup>+</sup>) or (e<sup>-</sup> + B<sup>-</sup>)] balances out the diffusion, and steady state condition is reached.

#### How a pn-junction comes into being



The net charge can be approximated as shown above.

How a pn-junction comes into being



# **Summary of Current Understanding**



- 1. When light creates an electron-hole pair, a *pn*junction can separate the positive and negative charges because of the built-in electric field.
- 2. This built-in electric field is established at a pnjunction because of the balance of electron & hole drift and diffusion currents.

# **In-Class Exercise**



















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#### **Carrier Motion**

Under equilibrium conditions in a homogeneous material: Individual carriers constantly experience Brownian motion, but the <u>net</u> charge flow is zero.

*To achieve net charge flow (current), carriers must move via <u>diffusion</u> or <u>drift</u>.* 

# Diffusion



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#### **Drift Current**



From PVCDROM

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### **Current Density Equations**

$$J_{e} = q\mu_{n}n\xi + qD_{e}\frac{dn}{dx}$$
$$J_{h} = q\mu_{h}p\xi - qD_{h}\frac{dp}{dx}$$
$$Dominates when \xi is when \xi is small}$$

**Einstein Relationships**: Relation between drift and diffusion:

$$D_{\rm e} = \left(\frac{kT}{q}\right) \mu_{\rm n}$$

$$D_{\rm h} = \left(\frac{kT}{q}\right)\mu_{\rm p}$$

## **What's ξ?**

#### From differential form of Gauss' Law (a.k.a. Poisson's Equation):

$$\frac{d\xi}{dx} = \frac{\rho}{\varepsilon}$$

 $\rho$  = charge density  $\varepsilon$  = material permittivity

We know the charge density is:

$$\rho = q\left(p - n + N_{\rm D}^+ - N_{\rm A}^-\right)$$
$$\rho \approx q\left(p - n + N_{\rm D} - N_{\rm A}^-\right)$$

 $N_{\rm D}^{+}$  = ionized donor concentration  $N_{\rm A}^{-}$  = ionized acceptor concentration

Assuming all dopants are ionized at room temperature

In summa:

$$\frac{d\xi}{dx} = \frac{q}{\varepsilon} \left( p - n + N_{\rm D} - N_{\rm A} \right)$$



## **Continuity Equations**

rate entering - rate exiting = 
$$\frac{A}{q} \left\{ J_{e}(x) - \left[ J_{e}(x + \delta x) \right] \right\}$$
  
=  $\frac{A}{q} \frac{dJ_{e}}{dx} \delta x$ 

rate of generation - rate of recombination =  $A\delta x(G-U)$ 

#### For electrons:

$$\frac{1}{q}\frac{dJ_{\rm e}}{dx} = U - G$$

For holes:

$$\frac{1}{q}\frac{dJ_{\rm h}}{dx} = -(U-G)$$



## System of Equations Describing Transport in Semiconductors



#### **Possible to Solve Analytically?**

No! Coupled set of non-linear differential equations.

#### Must solve numerically (e.g., using computer simulations)...

... or make series of approximations to solve analytically.

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#### New Concept: <u>Chemical Potential</u>

#### Band Diagram (E vs. x)



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#### New Concept: <u>Chemical Potential</u>

At absolute zero, no conductivity (perfect insulator).

#### Band Diagram (E vs. x)



### New Concept: <u>Chemical Potential</u>

At T > 0 K, some carriers are thermally excited across the bandgap.

#### Band Diagram (E vs. x)



### New Concept: Chemical Potential

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At T > 0 K, some carriers are thermally excited across the bandgap.

#### Band Diagram (E vs. x)



- The *chemical potential* describes the average energy necessary to add or remove an infinitesimally small quantity of electrons to the system.
- In a semiconductor, the chemical potential is referred to as the "Fermi level."



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We assume: All dopants are ionized!

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## Voltage Across a pn-Junction



#### Voltage Across a pn-Junction

![](_page_51_Figure_1.jpeg)

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#### **Derivation**

$$q \psi_{o} = E_{g} - \left(E_{F} - E_{V}\right) - \left(E_{C} - E_{F}\right)$$
$$= E_{g} - kT \ln\left(\frac{N_{V}}{N_{A}}\right) - kT \ln\left(\frac{N_{C}}{N_{D}}\right)$$
$$= E_{g} - kT \ln\left(\frac{N_{C}N_{V}}{N_{A}N_{D}}\right)$$
Built-in pn-junction potential a function of dopant concentrations.  
$$\psi_{o} = \frac{kT}{q} \ln\left(\frac{N_{A}N_{D}}{n_{i}^{2}}\right)$$

#### Voltage Across a pn-Junction

![](_page_53_Figure_1.jpeg)

### Voltage Across a Biased pn-Junction

![](_page_54_Figure_1.jpeg)

### **Effect of Bias on Width of Space-Charge Region**

![](_page_55_Figure_1.jpeg)

### **Effect of Bias on Width of Space-Charge Region**

![](_page_56_Figure_1.jpeg)

#### pn-junction, under dark conditions

![](_page_57_Figure_2.jpeg)

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#### **Carrier Concentrations Across a pn-Junction**

![](_page_59_Figure_1.jpeg)

Approximation 1: Device can be split into two types of region: quasineutral regions (space-charge density is assumed zero) and the depletion region (where carrier concentrations are small, and ionized dopants contribute to fixed charge).

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## Width of space charge region

![](_page_60_Figure_1.jpeg)

# Width of space charge region

![](_page_61_Figure_1.jpeg)

#### Capacitance

![](_page_62_Figure_1.jpeg)

#### Capacitance

![](_page_63_Figure_1.jpeg)

## **Pn-junction under <u>zero</u> bias**

![](_page_64_Figure_1.jpeg)

## **Pn-junction under <u>forward</u> bias**

![](_page_65_Figure_1.jpeg)

## **Pn-junction under <u>forward</u> bias**

![](_page_66_Figure_1.jpeg)

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![](_page_67_Figure_1.jpeg)

![](_page_68_Figure_1.jpeg)

![](_page_69_Figure_1.jpeg)

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![](_page_70_Figure_1.jpeg)

<u>Approximation 3</u>: Only cases where minority carriers have a much lower concentration than majority carriers will be considered,

i.e., 
$$p_{pa} >> n_{pa}$$
,  $n_{na} >> p_{na}$ 

$$p_{pa} = N_A + n_{pa}$$

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#### **Current densities**

Calculate (diffusive) currents in quasi-neutral region:

$$J_h = -qD_h \frac{dp}{dx}$$

... from previous slide ...

![](_page_71_Figure_4.jpeg)
#### **Current densities**

$$\frac{1}{q}\frac{dJ_e}{dx} = U - G = -\frac{1}{q}\frac{dJ_h}{dx}$$

Magnitude of the change in current across the depletion region:

$$\delta J_e = \left| \delta J_h \right| = q \int_{-W}^{0} (U - G) dx \approx 0$$

Key assumption: W is small compared to  $L_e$  and  $L_h$ . Therefore, integral is negligible. It follows that the current  $J_e$  and  $J_h$  are essentially constant across the depletion region, as shown below.



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#### **Ideal Diode Equation**

Since  $J_e$  and  $J_h$  are known at all points in the depletion region, we can calculate the total current:

$$J_{\text{total}} = J_e \big|_{x'=0} + J_h \big|_{x=0} = \left( \frac{q D_e n_{p0}}{L_e} + \frac{q D_h p_{n0}}{L_h} \right) \left( e^{q V/kT} - 1 \right)$$

This leads to the ideal diode law:

$$I = I_o \left( e^{qV/kT} - 1 \right) \text{ where}$$
$$I_o = A \left( \frac{qD_e n_i^2}{L_e N_A} + \frac{qD_h n_i^2}{L_h N_D} \right)$$

# **Key Point**

 The IV response of a pn-junction is determined by changes in *minority carrier current* at the edge of the space-charge region.

# **Readings are strongly encouraged**

- Green, Chapter 4
- <u>http://www.pveducation.org/pvcdrom/</u>, Chapters 3 & 4.

## pn-junction, under dark conditions



## pn-junction, under dark conditions



#### Hands-On: Measure Solar Cell IV Curves

2.627 / 2.626 Fundamentals of Photovoltaics Fall 2013

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